Parallel Pathways for Photocatalytic Decomposition of Acetic Acid on TiO₂

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Acetic acid decomposes photocatalytically on TiO2 at room temperature in an inert atmosphere through two parallel pathways. In one pathway, acetic acid decomposes to gas-phase CO₂ and apparently forms hydrogen and methyl groups, which combine on the surface to form CH₄. In the other pathway, acetic acid extracts oxygen from the TiO₂ lattice to form adsorbed H₂O and gas-phase CO₂ and C₂H₆. The extracted oxygen is replenished by diffusion from the bulk in an inert atmosphere or by gas-phase O2. The formation of CH₄ and CO₂ in the first pathway does not consume lattice oxygen. The first step in photocatalytic decomposition (PCD) of acetic acid appears to be dissociation of the O-H bond, producing surface acetates. However, molecularly adsorbed acetic acid reacts at the same rate and with the same selectivity as surface acetates. Only the α -carbon forms CO₂ during PCD. When gas-phase O₂ is present, adsorbed methyl groups oxidize before they are hydrogenated to CH₄. The oxidizing agent during photocatalytic oxidation (PCO) is different from that during PCD and is most likely adsorbed oxygen. Adsorbed oxygen reacts with acetic acid in a different pathway from the two reactions observed for PCD, so a Mars Van Krevlen mechanism for PCO appears unlikely. The TiO₂ surface is not homogeneous and some surface sites are more active during both PCD and PCO. Co-adsorbed water increases the rate of CH₄ formation, apparently by reacting with CH_{3(ads)} to form CH₄, but in contrast to adsorbed O₂, water does not react with acetic acid in a separate pathway that is different from those observed for PCD without water. © 1999 Academic Press

INTRODUCTION

Heterogeneous photocatalytic oxidation (PCO) has potential applications for complete oxidation of organic pollutants in dilute systems. A wide range of organics can be oxidized to CO₂ and H₂O *at room temperature* on TiO₂ catalysts in the presence of UV or near-UV illumination. The UV light excites electrons from the valence to the conduction band of the semiconductor catalyst, leaving holes behind. The electron-hole pairs can initiate redox reactions with surface species.

To clarify the relative importance of adsorbed and lattice oxygen during PCO, photocatalytic reaction of acetic acid was studied in the absence of gas-phase O_2 . This reaction will be referred to as photocatalytic decomposition (PCD) to distinguish it from PCO, which takes place when gas-phase O_2 is present. Acetic acid was used as a model reactant because it readily undergoes both PCD and PCO and it is a volatile organic compound (VOC) that it is formed during PCO of other organics, such as ethanol (1–3). Transient reaction was used to obtain a better understanding of the surface processes.

Kraeutler and Bard (4) studied liquid-phase PCD of acetic acid and sodium acetate solutions on TiO₂ and platinized TiO_2 in a batch reactor at 328 K. In the absence of molecular oxygen, acetic acid decomposed mainly to CH₄ and CO₂ with small amounts of C₂H₆ and H₂ also forming. The ratio of CH₄ to C₂H₆ was approximately 19 on TiO₂ and 11 on platinized TiO₂. When deuterated acetic acid (CH₃COOD, 98% atom enrichment) reacted on platinized TiO₂, 80% of the CH₄ product was monodeuterated, but C2H6 was not deuterated. The CH3COOD decomposed about half as fast as CH₃COOH. Furthermore, addition of O_2 largely suppressed both CH_4 and C_2H_6 formation. They proposed a mechanism in which acetic acid decomposes to CO_2 , $CH_{3(ads)}$, and $H_{(ads)}$. Methane forms by combining H_(ads) and CH_{3(ads)}, and C₂H₆ forms by recombination of two methyl radicals. They also discussed the possibility that CH_{3(ads)} reacts with H₂O_(ads) to produce CH₄.

Yoneyama *et al.* (5) also detected CO_2 , CH_4 , C_2H_6 , and H_2 as the major products from aqueous solutions of acetic acid and sodium acetate during illumination of Pt/TiO₂ in a batch reactor. Similarly, Chemseddine and Boehm (6) observed CO_2 formation during PCD of aqueous acetic acid and chloroacetic acids on TiO₂. Yoneyama *et al.* proposed a similar mechanism to that of Kraeutler and Bard (4), with the addition of another pathway,

 $CH_3 \bullet + CH_3COOH \rightarrow CH_4 + \bullet CH_2COOH.$

For anatase TiO_2 , the CO_2/CH_3 • mole ratio varied from 1.3 to 33; the CH_3 • amount was determined by adding the amounts of C_2H_6 and CH_4 . The authors attributed the greater than stoichiometric amounts of CO_2 produced to oxidation of ethanol and acetaldehyde intermediates.



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Their results for PCD at various pH values showed that the ratio of C_2H_6/CH_4 formation rates increased with reaction rate and decreased with reaction time. However, when the pH was fixed at 3.1 and the concentration of acetic acid increased, the ratio of C_2H_6/CH_4 decreased as the reaction rate increased. Finally, when the sodium acetate concentration was fixed, CH_4 and C_2H_6 rates and the C_2H_6/CH_4 ratio increased with increasing acetic acid concentration. Increasing the UV intensity also increased the C_2H_6 formation rate more than the CH_4 rate. The authors reasoned that the concentration of surface methyl groups increased when the rates increased, and thus second-order reactions should be favored. The C_2H_6/CH_4 ratio then increased if CH_4 and C_2H_6 were produced via first- and second-order reactions of methyl groups, respectively.

Nosaka *et al.* (7) used ESR to detect methyl radicals during PCD of acetic acid in water on TiO_2 . The authors proposed that a photo-induced hole reacts with acetic acid to produce CO_2 , CH_3 , and H^+ . They reasoned that the methyl radicals should predominantly form CH_4 .

Sclafani et al. (8) observed that gas-phase acetic acid decomposed photocatalytically to CH₄, CO₂, and small amounts of C₂H₆. For the two types of TiO₂ catalysts studied, the *steady-state* ratios of CO_2 to CH_4 were 1.7 and 20.6, and the rate of C₂H₆ formation was less than 0.3% of the CH₄ rate. Since the CO₂: CH₄ ratios were not one, as expected from stoichiometry, water must have also formed, but it could not be detected by their analysis. Moreover, since their product distributions were measured after long reaction times (40-70 h) that corresponded to steady state, some O₂ may have been present in their feed. They reported similar results for the other oxides studied; the CO₂/CH₄ ratio was greater than one, and the C₂H₆ rates were small. In contrast to the previous studies, they concluded that PCD occurred by excitation of an adsorbed species rather than by generation of electron/hole pairs in TiO₂. Also, in contrast to previous PCO studies (1, 2), Sclafani et al. observed that CH₄ still formed when O₂ was added to the feed and concluded that TiO₂ is less active in air than in He because the CH₄ production rate decreased by 25% in air. However, CO₂ could not be detected during their PCO experiments, and adsorbed CH₃ species produced during PCO probably oxidized to CO₂.

In a preliminary study (9), we showed that in the absence of gas-phase O_2 , acetic acid decomposes at room temperature by parallel pathways during transient experiments to form CH₄, C₂H₆, CO₂, and H₂O:

$$CH_{3}COOH \rightarrow CO_{2} + CH_{4}$$

$$2CH_{3}COOH + O_{(1)} \rightarrow C_{2}H_{6} + 2CO_{2} + H_{2}O$$

Isotope labeling showed that the α -carbon reacts exclusively to CO₂ whereas the β -carbon forms CH₄ and C₂H₆. Mass balances verified the indicated stoichiometries.

The objective of the current study is to understand the surface processes involved in PCD and how they relate to PCO, and to measure their rates. A monolayer of acetic acid was adsorbed on oxidized TiO₂, and any excess organic was flushed from the gas phase. The surface coverage of acetic acid was known at all times since no other carboncontaining species were detected on the surface when acetic acid decomposed. The TiO₂ surface with adsorbed acetic acid was exposed to UV illumination in the absence of gas-phase O₂, and the reaction products were detected by a mass spectrometer. Transient experiments are preferred over steady state experiments for reactions where the catalyst surface changes as lattice oxygen is removed. Since gasphase O₂ did not replenish the surface during PCD, lattice oxygen extraction and diffusion of bulk oxygen to the surface could be observed. In contrast to batch reactor studies where product gases were collected and analyzed after several minutes of reaction (4, 5), a mass spectrometer immediately detects gas-phase products and the instantaneous reaction rate and selectivity are measured. Interrupted PCDs for various dark times provided insight into the role of lattice oxygen and acetic acid coverage during PCD and PCO. In some experiments, oxygen, water, or acetic acid were also injected during UV illumination or in the dark after PCD to provide information on the roles of lattice oxygen, adsorbed water, and surface diffusion of acetic acid during PCD. In some experiments, ¹³C-labeled acetic acid (CH₃¹³COOH) was used to track the reactivity of the α and β carbons separately. The reaction mechanism was investigated by studying PCD and PCO of methyl acetate (CH₃COOCH₃), which has a methyl group in place of the acid hydrogen of acetic acid. Formic acid PCO was also used to provide insight into the reactivity of different surface sites. After PCD or PCO, species that remained on the surface were characterized by temperature-programmed desorption (TPD) or oxidation (TPO).

EXPERIMENTAL METHODS

The apparatus used for PCD, PCO, TPD, and TPO was described previously (10). Approximately 30 mg Degussa P-25 TiO₂ catalyst was coated as a thin layer (average thickness <0.5 μ m) on the inside of an annular Pyrex reactor so that all the TiO₂ was exposed to UV light for photocatalytic oxidation. The annular reactor had a 1-mm annular spacing so that high gas flow rates could be maintained across the catalyst to minimize mass transfer effects and rapidly flush gas-phase products from the reactor. The outside diameter of the reactor was 2 cm and the reactor was 13 cm high so that sufficient catalyst mass was present to allow detection of reaction products by the mass spectrometer. Six UV lamps (GE, 4 W) surrounded the photocatalytic reactor, and the light intensity at the catalyst surface, measured with a radiometer, was typically 0.3 mW/cm², but varying

UV intensity was used for some experiments. The radiometer only measured light from one direction, but the light that penetrated through the thin catalyst layer would strike the layer on the other side of the reactor, and thus, the intensity was greater than 0.3 mW/cm². This decreased intensity variations at different locations around the reactor, but the light was more intense at the midpoint of the reactor than at the ends. The maximum light intensity was near 360 nm (2).

Before each experiment the reactor was held at 723 K for 30 min in approximately $20\% O_2$ in He and then cooled to room temperature to create a reproducible surface. Two 1- μ L pulses of acetic acid (Aldrich, 99.99+%), ¹³Cacetic acid ($CH_3^{13}COOH$, Isotec, 99+% atom enrichment), methyl acetate (Aldrich, 99.5%), or formic acid (Sigma, 99%) saturated the catalyst in the dark at 300 K prior to PCD or PCO, and all experiments started with the surface saturated unless otherwise indicated. After exposure to an organic, the reactor was flushed for 2 h to remove gas-phase organic, so that only reaction of the adsorbed monolayer was studied. Photocatalytic decomposition was studied by illuminating the TiO₂ in 100 cm³/min STP of He flow, and PCO was carried out in 3% O₂ flow. For PCD, the He stream was purified and the flow system was designed and checked so that the O2 concentration was below the mass spectrometer detection limits. The O₂ concentration during PCD is estimated to be less than 0.3 ppm (11). Metal shields were placed between the reactor and the UV lights, and after the lights attained a steady state output, the shields were removed to illuminate the catalyst and initiate transient reaction at room temperature. The gas-phase products were detected by a mass spectrometer as a function of time.

To understand the roles of lattice oxygen and surface diffusion of acetic acid, the lights were turned off periodically for varying lengths of time during both PCD and PCO, and the effect of dark time on the subsequent rates of CH₄, C_2H_6 , and CO_2 formation was measured. In addition, for some experiments, pulses of O_2 (110 μ mol/g catalyst), acetic acid (110 μ mol/g catalyst), formic acid (160 μ mol/g catalyst), or H₂O (180 μ mol/g catalyst) were exposed to the catalyst in the dark or during UV illumination after PCD for several min.

A Balzers QMA 125 quadrupole mass spectrometer monitored the reactor effluent immediately downstream of the reactor. The mass spectrometer was interfaced to a computer to record multiple mass peaks simultaneously. The mass spectrometer signals were calibrated by injecting known volumes of gases into the flow stream downstream of the reactor, and signals were corrected for cracking in the mass spectrometer. After PCO or PCD, TPD or TPO was performed by heating the catalyst at 1 K/s to 723 K and holding at this temperature until no desorption products were detected. An He flow gas was used for TPD whereas a 20% O₂ in He gas mixture was used for TPO.

RESULTS AND DISCUSSION

As we previously reported (9), a monolayer of acetic acid decomposes on TiO₂ to form gas-phase CO₂, CH₄, and C₂H₆ during UV illumination in an inert gas stream. Figure 1 shows the rate of formation of products as a function of time during acetic acid PCD. Upon UV illumination, the rate of CO₂ production immediately reaches a maximum, quickly decreases to 0.08 μ mol/g catalyst/s, and then decreases more slowly. The rate of C₂H₆ formation also decreases quickly after reaching its initial maximum, and then decreases much more slowly. In contrast, the CH₄ formation rate does not exhibit a sharp maximum and decreases slowly throughout the PCD. All signals drop to zero when the lights are turned off. When UV illumination resumes after 420 s in the dark, the CO_2 rate is 1.5 times and the C_2H_6 rate is 4.5 times the rates measured before the lights were turned off. In contrast, the CH₄ rate production is the same as that before the dark time.

During PCD of CH₃¹³COOH, only ¹³CO₂, ¹²C₂H₆, and ¹²CH₄ are detected. That is, the α -carbon is oxidized exclusively to CO₂, and β -carbon only forms CH₄ and C₂H₆. These results suggest two parallel pathways for acetic acid decomposition during PCD:

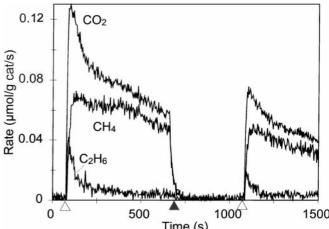
$$CH_3^{13}COOH_{(ads)} \rightarrow {}^{13}CO_{2(g)} + CH_{4(g)}$$
 [1]

$$2 CH_3{}^{13}COOH_{(ads)} + O_{(l)} \rightarrow C_2H_{6(g)} + 2 {}^{13}CO_{2(g)} + H_2O_{(ads)}$$
[2]

Note that the acid hydrogens form H_2O in reaction [2], but the H atoms may also be present on the surface as $OH_{(ads)}$ groups. As reported previously (9) for these reactions, the rate of CO₂ formation equals the sum of the CH₄ rate plus twice the C_2H_6 rate for the entire time of the experiment. These signals are coincident when plotted this way.

0.12 CO₂ 0.08 0.04 0 n 500 1000 1500 Time (s)

FIG. 1. Product formation rates during photocatalytic decomposition in He flow of a monolayer of acetic acid on TiO2. The UV lights were turned on (open triangles) and off (solid triangles) as indicated.



Reaction [1] does not require oxygen whereas reaction [2] does. Presumably lattice oxygen is extracted in reaction [2] since no gas-phase oxygen was present during PCD. Thus, the rates of C_2H_6 and CO_2 formation are greater after the dark time because lattice oxygen diffuses from the TiO₂ bulk to replenish the surface oxygen vacancies in the dark, as was seen for PCD of formic acid (11). The higher concentration of surface oxygen after the dark time increases the rate of reaction [2]. Indeed, the rate increase for CO_2 in Fig. 1 after the dark time is approximately twice that for C_2H_6 , as expected for reaction [2] stoichiometry. Also, the rates of C₂H₆ and CO₂ formation drop rapidly from their initial rates as lattice oxygen is removed from the surface. In contrast, the CH₄ rate after a dark time is the same as before the lights were turned off since reaction [1] does not require lattice oxygen. For the same reason, the CH₄ rate drops more slowly with time than the C₂H₆ rate. Presumably, acid hydrogens combine with CH₃ groups to form CH₄ during acetic acid PCD. However, during formic acid PCD, acid hydrogens do not combine with each other or with the hydrogen originally bound to the carbon (11). Similarly, no H₂ forms during PCD of acetic acid by recombination of two acid hydrogens. Thus, adsorbed methyl groups may react with H_2O to produce CH_4 , as proposed by Kraeutler and Bard (4).

During TPD after PCD, only acetic acid and the products of its bimolecular ketonization (acetone, CO_2 , and H_2O) desorb from the TiO₂ surface. The TPD spectra are similar to those previously reported for TPD of acetic acid without reaction [1]. That is, only acetic acid and H₂O are on the surface after PCD; if methyl groups formed during PCD, they quickly reacted to form CH₄. The H₂O seen during TPD can be from both the ketonization reaction and reaction [2], since H_2O that forms during PCD adsorbs strongly on TiO₂. The appearance of gas-phase products (CH_4 , C_2H_6 , and CO₂) during PCD is reaction limited since these species are too weakly adsorbed on TiO₂ to have a significant coverage at room temperature. No desorption products were detected during TPD after exposing TiO_2 to CH_4 or C_2H_6 , and only a small amount of CO_2 adsorbed on TiO_2 (12). During PCO of a monolayer of acetic acid, both formaldehyde and formate reaction intermediates are on the surface [1], but neither was detected during TPD after PCD. Thus it appears that lattice oxygen does not oxidize the CH₃ groups. This is confirmed since ¹²CO₂ does not form during PCD of CH₃¹³COOH. This indicates that adsorbed oxygen is necessary for some oxidation steps during PCO, whereas lattice oxygen may be used in others. Although gas-phase O_2 is not needed to oxidize the α carbon in acetic acid to CO₂, it is required to oxidize the β carbon.

Photocatalytic Decomposition with O₂ Injections

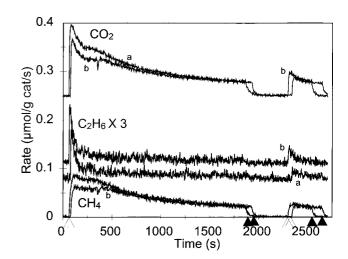
As described above, oxygen from the TiO_2 bulk diffuses to replenish the surface vacancies when the lights are turned

FIG. 2. Product formation rates during photocatalytic decomposition of a monolayer of acetic acid on TiO_2 . After approximately 1900 s, the lights were turned off for 420 s and during the dark time (a) no change was made in the system or (b) a pulse of O_2 was injected over the TiO_2 . The UV lights were turned on (open triangles) and off (solid triangles) as indicated.

off following PCD. Figure 2 shows results from two PCDs of acetic acid. Both PCDs have a 420-s dark time. The second PCD is at a UV intensity that is 83% of that in the first experiment, and a 110 μ mol/g catalyst pulse of O₂ is injected during the dark time. Initially, the CH₄ and C₂H₆ rates are 1.4 and 1.2 times greater, respectively, at the higher light intensity. After the initial maxima, the C₂H₆ rates essentially coincide until after the 420-s dark time. The difference in the rates of CH₄ production decreases until eventually the two rates are almost the same after 1700 s. The rates are expected to cross eventually since the greater rate at the higher UV intensity consumes acetic acid faster.

After the dark time, the rates of CH₄ formation are essentially the same for both experiments and equal to the rates before the dark time. This indicates that lattice oxygen is not required for CH_4 formation (reaction [1]) since the O_2 pulse in the dark replenishes lattice oxygen that was extracted during PCD. It also indicates that the adsorbed oxygen coverage is low after the O_2 pulse since adsorbed oxygen would be expected to photocatalytically oxidize adsorbed CH₃; the CH₄ formation rate did not decrease after the dark time. The C₂H₆ rate after the O₂ pulse in the dark is twice the C_2H_6 rate without the O_2 injection, even though the UV intensity is lower for the O₂ pulse experiment. Since the O_2 replenished the lattice oxygen, reaction [2] for C_2H_6 is expected to be faster. These experiments were repeated using the same UV intensity for each with similar results; the O_2 pulse during the dark time increased the C_2H_6 rate, but not the CH₄ rate.

Figure 3 shows the effect of an O_2 pulse injected *with the UV lights on during PCD* of CH₃¹³COOH. After 1000 s, an O_2 pulse (560 μ mol O_2/g catalyst) quadruples the rate of



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FIG. 3. Product formation rates during photocatalytic decomposition of a monolayer of acetic acid on TiO_2 . Pulses of O_2 were injected over the TiO_2 at 1000 and 1700 s with the UV lights on.

 $^{13}CO_2$ formation, *decreases* the rate of CH₄ production by 40%, and *increases* the C_2H_6 formation rate a factor of 3.5. In addition, ¹²CO₂ forms as O₂ oxidizes the β -carbon; the $^{12}CO_2$ rate is 27% of the $^{13}CO_2$ rate. As shown in Fig. 2, O₂ readily oxidizes reduced TiO₂ in the dark and produces an increase in the rate of C_2H_6 formation. The dramatic decrease in the CH₄ rate in Fig. 3, combined with the appearance of ${}^{12}CO_2$, indicates that surface methyl groups, if produced during PCD, react quickly with oxygen to form CO₂ before they are hydrogenated to CH₄. The decrease in the CH₄ rate upon O₂ injection cannot be attributed to subsequent oxidation of gas-phase CH₄ to CO₂ since less than 1% of an injected CH₄ pulse oxidizes to CO₂ over fresh, illuminated TiO₂ in flowing 20% O₂. After 1700 s of PCD, a 220 μ mol/g catalyst pulse of O₂ produces similar results as the larger pulse.

Gas-phase O_2 decreases the rate of CH_4 production, presumably because CH_3 groups are oxidized faster than they are hydrogenated, or because adsorbed and lattice oxygen oxidize H atoms before they can react with the CH_3 groups. This implies that injecting O_2 during PCD decreases either the coverage of adsorbed methyl groups or the coverage of surface H atoms. The C_2H_6 rate *increased* during the O_2 injection, which suggests that either the CH_3 surface concentration increased because the H atoms were removed or C_2H_6 does not form by recombination of surface methyl groups. Part or all of this rate increase is due to the increase in lattice oxygen. If CH_3 groups do not recombine to make C_2H_6 , some other bimolecular reaction may produce C_2H_6 during PCD.

Note in Fig. 3 that the ${}^{13}CO_2$ rate increased to approximately 0.17 μ mol/g cat/s after the first O₂ injection whereas the rate of ${}^{13}CO_2$ formation expected from reactions [1] and [2] (the sum of the CH₄, ${}^{12}CO_2$, and twice the C₂H₆ rates)

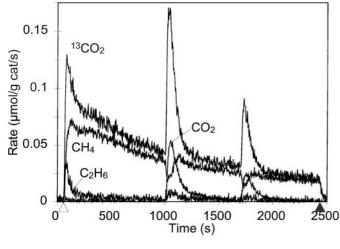
is only 0.09 μ mol/g cat/s. Furthermore, the amount ¹²CO₂ produced during the first O₂ pulse was 7.5 times the uptake of CH₄. Since TPD after PCD showed no long-lived intermediates during PCD, the excess ¹²CO₂ must have been produced by acetic acid reacting with adsorbed oxygen. The second O₂ pulse produced similar results. These observations indicate that adsorbed oxygen, which is present during PCO but not PCD, reacts with acetic acid in a different pathway than either reaction [1] or [2]. Therefore, the mechanism for PCO is expected to be different than that of PCD. Furthermore, PCO and PCD studies of formic acid (11) indicate that the TiO_2 surface is not oxygen deficient during PCO in 3% O₂ flow. This means that either lattice oxygen does not participate in PCO or any oxygen extracted from the surface is quickly replenished by the gas phase. Figures 2 and 3 show that adsorbed oxygen replenishes reduced TiO₂ at room temperature in the dark and during UV illumination, as seen during formic acid PCD (11).

Acetic Acid injection

Figure 4a shows PCD of a monolayer of acetic acid with a 110 μ mol/g catalyst pulse of CH₃¹³COOH injected during UV illumination at 950 s. After the ¹³C-acetic acid injection, $^{13}CO_2$ forms and the $^{12}CO_2$ and CH₄ rates are 1.4 and 1.7 times their respective rates before the injection. The ${}^{12}CO_2$ rate increases even though the ¹²C-acetic acid coverage did not increase. If reaction [2] is second-order in acetic acid concentration, the ¹²CO₂ rate should increase with the addition of CH₃¹³COOH to the surface. The ¹³CO₂ rate after the injection was approximately one-third of the total CO_2 rate, even though ¹³C-acetic acid comprised only 20% of the total acetic acid coverage. This indicates a possible heterogeneity of UV intensity, or some sites are more active for PCD since the ¹³C-acetic acid injection might preferentially adsorb on the more active sites. The rate of CH₄ formation after ¹³C-acetic acid injection was nearly equal to its initial rate, indicating that the total acetic acid coverage after the ¹³C-acetic acid injection was near saturation. The CH₄ rate after injection equaled the initial rate even though lattice oxygen was removed during PCD, because the pathway to form CH₄ does not require lattice oxygen.

The C₂H₆ rate after the injection was only 60% of the initial rate, even though the acetic acid coverage was nearly a monolayer. A lower rate is expected since PCD extracts lattice oxygen, and C₂H₆ formation requires lattice oxygen. The rate of C₂H₆ production after the injection is eight times the rate before the injection, however. The dramatic increase in the rate of C₂H₆ formation is partly because C₂H₆ forms in a bimolecular reaction. However second-order kinetics would predict a doubling of the rate, based on the increase in acetic acid coverage, suggesting that some TiO₂ sites are more active for C₂H₆ formation.

Figure 4b shows PCD of a monolayer of acetic acid with a 110 μ mol/g catalyst pulse of CH₃¹³COOH injected in the



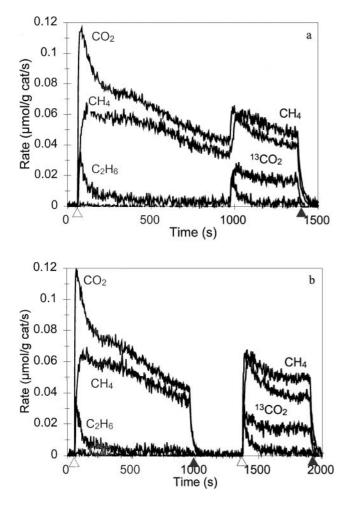


FIG. 4. Product formation rates during photocatalytic decomposition of a monolayer of acetic acid on TiO_2 . (a) A pulse of $CH_3^{13}COOH$ was injected at 900 s with the UV lights on. (b) A pulse of $CH_3^{13}COOH$ was injected at 900 s during the 420 s dark time. The UV lights were turned on (open triangles) and off (solid triangles) as indicated.

dark at 950 s. When UV illumination resumes, ${}^{13}CO_2$ forms at essentially the same rate as in Figure 4a, and the ${}^{12}CO_2$ and CH₄ rates are 1.6 and 1.7 times their respective rates before the dark time. The C₂H₆ rate after the dark time is approximately 90% of the initial rate, but does not equal the initial rate, presumably because diffusion of bulk oxygen to the surface was not complete after 420 s in the dark. The C₂H₆ rate increases more when ${}^{13}C$ -acetic acid is injected during the dark than when ${}^{13}C$ -acetic acid was injected during UV illumination since C₂H₆ formation requires lattice oxygen and oxygen from the bulk replenished the surface during the dark time. Similar to in Fig. 4a, the rate of CH₄ formation after the dark time is equal to the initial rate, indicating the coverage after injection equals the initial coverage.

Heterogeneity of Surface Sites

A similar experiment to that in Fig. 4b was done with formic acid to determine whether the changes in the rates

are because most reaction takes place on a small number of highly active sites. We have seen that formic acid also undergoes PCD on TiO₂ (11). After 1200 s of PCD of a monolayer of formic acid, 90 μ mol HCOOH/g catalyst was injected with the lights on. This pulse increased the HCOOH coverage from 0.9 to 1 mL and the subsequent rate of CO₂ production was 2.5 times the rate before the pulse. The injected formic acid is expected to adsorb on active sites that were empty after 1200 s of PCD. Since the rate after the formic acid injection was about 25% of the initial CO₂ production rate but the surface was saturated, PCD is not limited by surface diffusion of formic acid to active sites but instead is limited by the availability of surface lattice oxygen. That the CO₂ rate increased a factor of 2.5 after only 10% of a monolayer was added suggests that some sites are more active for PCD of formic acid, and the rate increase is not caused by nonuniform UV illumination.

Role of Weakly Bound Acetic Acid

Titania covered with a monolayer of acetic acid was heated to 450 K to desorb weakly bound acetic acid. Kim and Barteau (13) concluded that reversibly adsorbed acetic acid is not dissociated on anatase TiO₂, and more strongly adsorbed acetic acid dissociates to form acetate. Heating to 445 K desorbs weakly bound acetic acid so that 85% of a monolayer is left on the surface. During the subsequent PCD, the initial rates of C_2H_6 and CH_4 formation are approximately 75 and 81%, respectively, of those for PCD of a monolayer of acetic acid. Since the PCD rate is approximately proportional to coverage, undissociated acetic acid apparently reacts the same as surface acetate or it reacts to first form surface acetate. For PCD in the liquid phase, Yoneyama et al. (5) observed that when sodium acetate concentration was fixed and acetic acid concentration increased, CH₄ and C₂H₆ rates and the C₂H₆/CH₄ ratio increased after 15.5 h in a batch reactor. From this they suggested that undissociated acetic acid participates in the reaction. However, the increase in the C_2H_6/CH_4 ratio with increasing acetic acid concentration does not necessarily indicate that molecularly adsorbed acetic acid reacts differently from surface acetate. It could be attributed to higher acetic acid concentrations, which should increase the rate of the bimolecular reaction to form C₂H₆ more than the CH₄ rate.

UV Intensity

Decreasing the light intensity by 88% after several minutes of PCD decreases the overall reaction rate by an order of magnitude, but the selectivity is the same. The UV intensity was then set to its original value for several minutes. A subsequent increase to approximately 1.4 times the original UV intensity increases the rate of CH₄ production by 40%, whereas the C_2H_6 formation rate increases by only 20%. The C_2H_6 formation rate increases less than the CH₄ since it is limited at the higher intensities by availability of lattice oxygen and coverage of acetic acid. Note in Fig. 2 that the higher UV intensity increases the initial rate of CH₄ formation more than the initial C_2H_6 rate. Furthermore, the C_2H_6 formation rates for the two UV light intensities coincide after 30 s of UV illumination whereas the higher UV intensity produces a significantly greater CH₄ rate for 600 s and a slightly greater rate throughout PCD. This is consistent with other results that show surface concentration of acetic acid and availability of lattice oxygen limit the rate of C_2H_6 formation.

Co-adsorbed Water

Water did not change the rate of formic acid PCD when it was injected either in the dark or during UV illumination, indicating that water at room temperature does not oxidize the reduced TiO₂ (11). In contrast, Fig. 5 shows PCD of an acetic acid monolayer when pulses of H₂O are injected during UV illumination and in the dark. Water injection at 800 s more than doubles the CO₂ and CH₄ rates, whereas the C_2H_6 rate is 4.8 times the rate before the injection. A portion of the rate increase could be because water displaces acetic acid to more active sites that are vacant because acetic acid on these sites reacted first. The increase in the rate of reaction [2] could be completely due to acetic acid displacement to more active sites, since the C₂H₆ rate after injection is only about half the initial rate. However, note that the CH₄ rate during the water pulse is greater than the initial rate, indicating that water increases the rate of reaction [1]. This rate may increase because methyl groups abstract hydrogen from water to form CH₄. Kraeutler and Bard (4) suggested the possibility of methyl radicals reacting with a trapped electron to form a methyl anion. This

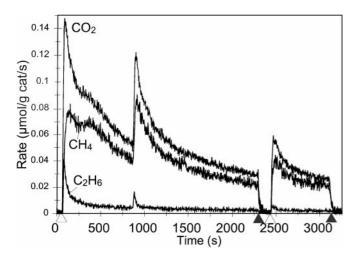


FIG. 5. Product formation rates during photocatalytic decomposition of a monolayer of acetic acid on TiO_2 . The lights were turned on and off as indicated by the open and solid triangles, respectively. Water was injected after 800 s (with the UV lights on) and 2300 s (in the dark).

anion could react with water to form CH₄:

$$e_{\mathrm{tr}}^- + \mathrm{CH}_{3(\mathrm{ads})} \rightarrow \mathrm{CH}_{3(\mathrm{ads})}^-$$

 $\mathrm{CH}_{3(\mathrm{ads})}^- + \mathrm{H}_2\mathrm{O} \rightarrow \mathrm{CH}_4 + \mathrm{OH}^-.$

A pulse of water during the 120-s dark period nearly doubles the CH_4 rate and triples the C_2H_6 rate. The rate increases for both CH_4 and C_2H_6 are not as large as the previous pulse in the light, most likely because less acetic acid was on the surface. The amount of CO_2 produced during the water injections is equal to the amount of CH_4 plus twice the amount of C_2H_6 . This indicates that water does not react with acetic acid by another pathway, in contrast to adsorbed O_2 . Water could increase the rate by displacing acetic acid to more active sites and acting as a hydrogen source for reaction [1].

Initial Steps of Photocatalytic Decomposition

When a monolayer of methyl acetate is exposed to UV light in He flow, *no reaction takes place*. Subsequent TPO confirmed that methyl acetate coverage was similar to that of acetic acid. The lack of reaction indicates that the first step in acetic acid PCD is abstraction of acid hydrogen to form adsorbed acetate. This result agrees with the observation by Kraeutler and Bard (4) that during PCD in the liquid phase, CH₃COOH decomposed almost twice as fast as CH₃COOD.

Although methyl acetate does not react during PCD, it readily oxidizes to CO_2 and H_2O in the presence of gasphase O_2 . This suggests that the oxidizing agent for PCO is different from that for PCD. Apparently adsorbed oxygen oxidizes organics during PCO, whereas lattice oxygen only oxidizes some species, such as the acid hydrogen in acetic acid. This suggests that a Mars Van Krevlen mechanism for PCO is not likely, since the oxidizing species would then be the same for PCD and PCO. Since the only difference between PCD and PCO is gas-phase O_2 , the oxidizing agent for PCO is most likely an adsorbed oxygen species.

Gravelle *et al.* (14) observed that gas-phase O_2 produced O_2^- on illuminated TiO₂. The O_2^- surface concentration decreased when the catalyst was exposed to isobutane and UV illumination, but no reaction took place between isobutane and O_2^- in the dark. Similarly, Linsebigler *et al.* (15) concluded that an excited O_2 species oxidized CO to CO₂ on illuminated TiO₂(110) and this species was most likely either O_2^- or O_2^{2-} . Lu *et al.* (16) showed that CH₃Cl did not react on TiO₂(110) except in the presence of O₂.

CONCLUSIONS

In an inert atmosphere, acetic acid photocatalytically decomposes on TiO_2 at room temperature through parallel pathways to form CO_2 , CH_4 , and C_2H_6 , but methyl acetate does not decompose under the same conditions. Acetic

acid extracts lattice oxygen during C₂H₆ formation. Oxygen extracted during acetic acid photocatalytic decomposition (PCD) is replenished by diffusion from the bulk or from gas-phase O₂ when present. Lattice oxygen is not consumed to produce CH₄ during PCD, and adsorbed O₂ quickly oxidizes either $CH_{3(ads)}$ or $H_{(ads)}$ before they recombine with H to produce CH₄. Some sites have higher activity during both PCD and PCO. Dissociation of the O-H bond appears to be the first step in PCD and subsequent reaction occurs via the resulting acetate species. The oxidizing agent during photocatalytic oxidation (PCO) is different from that during PCD and is most likely adsorbed oxygen. Adsorbed oxygen reacts with acetic acid in a different pathway from the two reactions observed for PCD, so a Mars Van Krevlen mechanism for PCO is unlikely. Water increases the rate of CH₄ formation, apparently by reacting with methyl groups, but in contrast to adsorbed O₂, it does not react with acetic acid in a separate pathway from PCD.

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